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(57) Abstract: The invention relates to a method for surface treating the surface (11') of a metal. The surface treatment is performed in a surfacing chamber (33), using a surfacing material (10), which is formed of one or more compounds and possible additives, and in which: the surfacing material (10) is brought to a principally gaseous state; the surfacing material (10) is led to the chamber (33); and the surfacing material (10) is permitted to react with the metal surface (11') being treated. The metal surface (11') being treated is subjected in the chamber (33) to a passing flow of the surfacing material (10), and in which the said surfacing material (10) comprises compound arising in dry distillation of deciduous-wood. The invention also relates to the equipment and surfacing material used in the method.

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